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Author(s)	Chen, Binjie; Hasegawa, Tetsuya; Ohta, Hiromichi; Katayama, Tsukasa
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1 **Antiferroelectric-to-ferroelectric phase transition in hexagonal rare-earth**
2 **iron oxides**

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4 Binjie Chen¹, Tetsuya Hasegawa², Hiromichi Ohta³, Tsukasa Katayama^{3,4*}

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6 ¹Graduate School of Information Science and Technology, Hokkaido University, N14W9, Kita,
7 Sapporo 060-0814, Japan.

8 ²Department of Chemistry, The University of Tokyo, Bunkyo, Tokyo 113-0033, Japan.

9 ³Research Institute for Electronic Science, Hokkaido University, N20W10, Kita, Sapporo 001-0020,
10 Japan.

11 ⁴JST-PRESTO, Kawaguchi, Saitama 332-0012, Japan

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13 *Corresponding author: katayama@es.hokudai.ac.jp

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1 **Abstract**

2 Ferroic oxides often exhibit exotic behavior, accompanied by phase transitions. Hexagonal
3 rare-earth iron oxides (h -RFeO₃), a promising multiferroic system, were reported to exhibit
4 ferroelectricity (FE) when the lattice parameter ratio (c/a) exceeded 1.93 and antiferroelectricity (AFE)
5 when c/a equaled to 1.89. Although the AFE–FE phase boundary in h -RFeO₃ systems is assumed to
6 exist at $c/a \approx 1.9$, the phase transition has not been observed so far due to the lack of samples with such
7 c/a ratio. In this study, we show AFE–FE phase transition in h -RFeO₃ films, where $R = \text{Dy}$. We
8 fabricated h -DyFeO₃ films with c/a ratios of 1.90–1.92 by controlling the film thicknesses. The h -
9 DyFeO₃ films with c/a of 1.91 exhibited AFE at temperatures below 200 K and FE at temperatures up
10 to 300 K. The phase transition temperature (T_p) was modulated by the c/a ratio. The films also
11 underwent an AFE–FE phase transition upon adjusting the frequency of voltage applied at the T_p . We
12 discuss the possible origin of the AFE–FE phase transition from the viewpoint of the migration length
13 of the FE domain wall motion.

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1 **1. Introduction**

2 Phase transition in ferroic materials provides fascinating features, which would achieve low-
3 energy-consumption devices and high-density memory storage devices. For example, giant
4 permittivity arising from a ferroelectric (FE)-to-paraelectric transition has been applied to various
5 devices, such as capacitors, antennas, and phase shifters [1-3]. On the other hand, electric field (E)-
6 induced magnetization change is realized, at room temperature, by using a ferromagnetic (FM)-to-
7 paramagnetic transition [4,5]. In such a conventional ferro-to-para transition, spontaneous polarization
8 or magnetization drops to zero at the transition temperature. In contrast, in the recently discovered
9 antiferro-to-ferro transition, the spontaneous polarization/magnetization value increases sharply with
10 the temperature (T) associated with the phase transition. Examples of AFE-to-FE transition materials
11 include $\text{Hf}_{1-x}\text{Zr}_x\text{O}_2$ [1,6], PbZrO_3 [7], $\text{Bi}_{1-x}\text{R}_x\text{FeO}_3$ (R is a rare-earth element) [8], and hexagonal (h -)
12 RMnO_3 [9-11], while examples of antiferromagnetic to FM transition materials include FeRh [12,13],
13 $\text{Sr}_x\text{R}_{1-x}\text{MnO}_3$ [14], and $\text{RBaCo}_2\text{O}_{5.5}$ [15,16]. These phase transitions also provide unique properties,
14 such as E -tunable large pyroelectric and electrocaloric effects near room temperature [17,18], giant
15 magnetoresistance [15], a sign change in magnetocapacitance [10], and current-induced phase
16 transition [19]. However, the limited number of materials exhibiting antiferro-to-ferro phase transition
17 properties necessitates the discovery of new systems.

18 h - RFeO_3 materials, exhibiting FE and magnetic orders simultaneously, have been intensively
19 studied as promising multiferroic materials owing to their high FE ordering temperatures and strong
20 coupling between magnetic and FE domains [20-23]. The FE polarization is derived from the
21 geometric tilting of FeO_5 bipyramids and the corresponding displacement of the R ion [21]. Because
22 this tilting is related to the lattice parameters, the FE properties can be modulated by changing the c/a
23 ratio [24]. For example, h - RFeO_3 exhibits FE behavior when c/a exceeds 1.93 [25-29], while it shows
24 AFE behavior when $c/a = 1.89$ [24]. However, the boundary between the AFE and FE phases remains
25 unknown, resulting in an absence of AFE–FE phase transition in one crystal of h - RFeO_3 . For attaining

1 AFE–FE phase transition in a multiferroic h -RFeO₃ system, we systematically investigated
2 ferroelectric properties of h -DyFeO₃ epitaxial films by tuning c/a ratio by changing the thickness. As
3 a result, we successfully observed T -induced AFE–FE phase transition phenomena. The variable c/a
4 (1.90–1.92) is intermediate between those of previously reported AFE and FE h -RFeO₃. The 38-nm-
5 thick h -DyFeO₃ ($c/a = 1.91$) underwent AFE–FE phase transition at 200 K. The phase transition
6 temperature can be modified by changing the c/a and/or frequency of the applied voltage.

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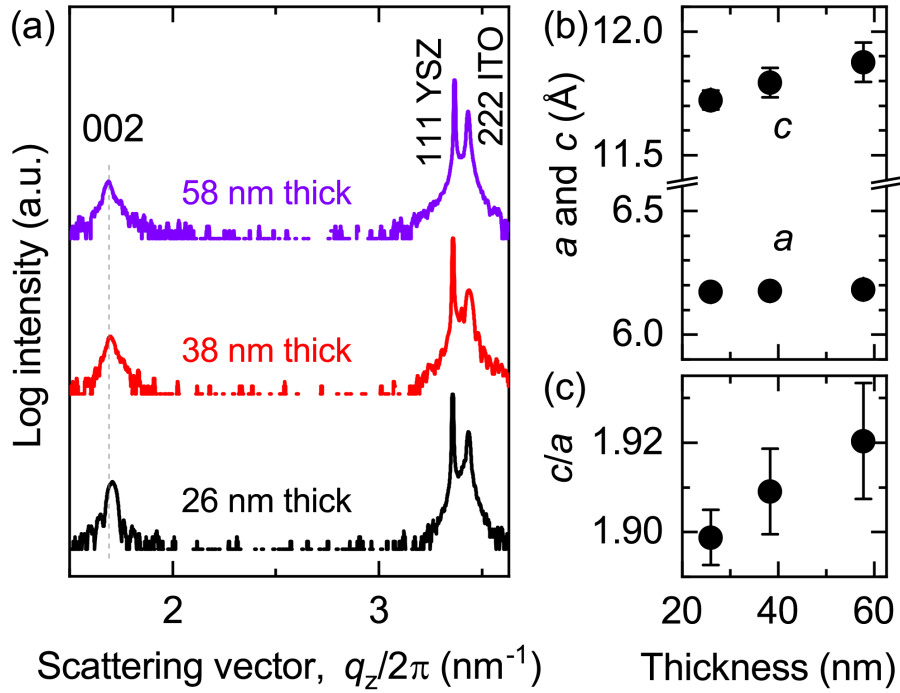
8 **2. Experimental**

9 h -DyFeO₃ films and indium tin oxide (ITO) bottom electrode layers were fabricated on (111)-
10 oriented yttria-stabilized zirconia (YSZ) substrates by pulsed laser deposition (PLD), where a KrF
11 excimer laser ($\lambda = 248$ nm) was used to irradiate on ceramic ITO and DyFeO₃ targets. The DyFeO₃
12 target was prepared by solid-state reaction techniques with Dy₂O₃ (99.9%) and α -Fe₂O₃ (99.9%)
13 powders. The stoichiometrically mixed powder was calcined at 1200 °C for 48 hours, mechanically
14 pressed into a pellet and sintered at 1400 °C for 12 hours. Epitaxial ITO layers were first deposited on
15 the YSZ substrate at 900 °C in an oxygen atmosphere (partial pressure of oxygen (P_{O_2}) = 2×10^{-3} Pa),
16 and then the h -DyFeO₃ film was heteroepitaxially grown on the ITO/YSZ substrate at 800 °C under a
17 P_{O_2} of 4 Pa [30,31]. After the deposition, the film is naturally cooled at P_{O_2} of 4 Pa. The film thickness
18 and crystal structure were determined using high-resolution X-ray diffraction (XRD, ATX-G, Rigaku
19 Co.) analysis with Cu K α_1 ($\lambda = 0.15406$ nm) radiation. Chemical composition difference between the
20 films was analyzed by employing scanning electron microscope–energy dispersive X-ray spectroscopy
21 (SEM–EDS). The ferroelectric properties of the h -DyFeO₃ films were analyzed using a ferroelectric
22 tester (Multiferroic II Ferroelectric Tester, Radiant Technologies Inc.). A 100- μ m-diameter Pt
23 electrode, used as the top electrode, was deposited by electron beam evaporation. The measurements
24 were performed at variable temperatures between 14 and 300 K. **Atomic force microscopy (AFM,**
25 **MFP-3D Origin, Oxford) was used to observe the topographic microscopy image and the**

1 piezoresponse force microscopy image.

3 3. Results and discussion

4 Figure 1(a) and S1 shows the out-of-plane XRD patterns of the 26-, 38-, and 58-nm-thick *h*-
5 DyFeO₃ films grown on ITO / (111) YSZ substrates. The diffraction peaks at $q_z/2\pi = 1.70, 3.37,$ and
6 3.43 nm^{-1} correspond to the 002 *h*-DyFeO₃, 111 YSZ, and 222 ITO peaks, respectively [24], indicating
7 that *c*-axis-oriented *h*-DyFeO₃ films were successfully prepared on (111) ITO epitaxial bottom
8 electrodes. The 001 *h*-DyFeO₃ peaks were shifted slightly to lower angles with increasing thickness;
9 the lattice parameter *c* monotonically increases from 11.74 to 11.87 Å with increasing the thickness
10 from 26 to 58 nm (Fig. 1(b)). Notably, ϕ -scan measurements revealed that heteroepitaxial growth
11 occurred in all *h*-DyFeO₃ films (Fig. S2). To evaluate the in-plane lattice parameter *a*, in-plane XRD
12 measurements were performed along the [11-2] YSZ direction (Fig. S3). From the 110 and 220
13 diffraction peaks, the lattice parameter *a* of the films was calculated to be almost independent of the
14 thickness (6.18 Å). Depending on the thickness, the *c/a* ratio was varied from 1.90 to 1.92 (Fig. 1(c)),
15 which was intermediate between those of previously reported AFE (*c/a* = 1.894) and FE (*c/a* ≥ 1.933)
16 *h*-RFeO₃ [23-29]. It was also indicated that the volume of the unit cell increased with increasing
17 thickness. Figure S5 shows EDS spectra of the films. The integral area ratio of Dy M α to Fe L α peaks
18 was 2.498, 3.115 and 3.242 for the 26-, 38-, and 58-nm-thick films, respectively, suggesting that Dy/Fe
19 composition ratio increases with increasing the thickness. Such thickness dependence of composition
20 difference was also observed in other oxide films such as CuFeO₂ [32] and Ba_{1-x}Sr_xTiO₃ [33] due to
21 the weakening of substrate strain or clamping effect with increasing thickness. It was reported that *c*-
22 axis length of isostructural *h*-LuFeO₃ increase with increasing Dy/Fe composition ratio [34,35]. Thus,
23 the increase of *c*-axis length in the *h*-DyFeO₃ films with increasing thickness is probably derived from
24 an increase in the Dy/Fe composition ratio.



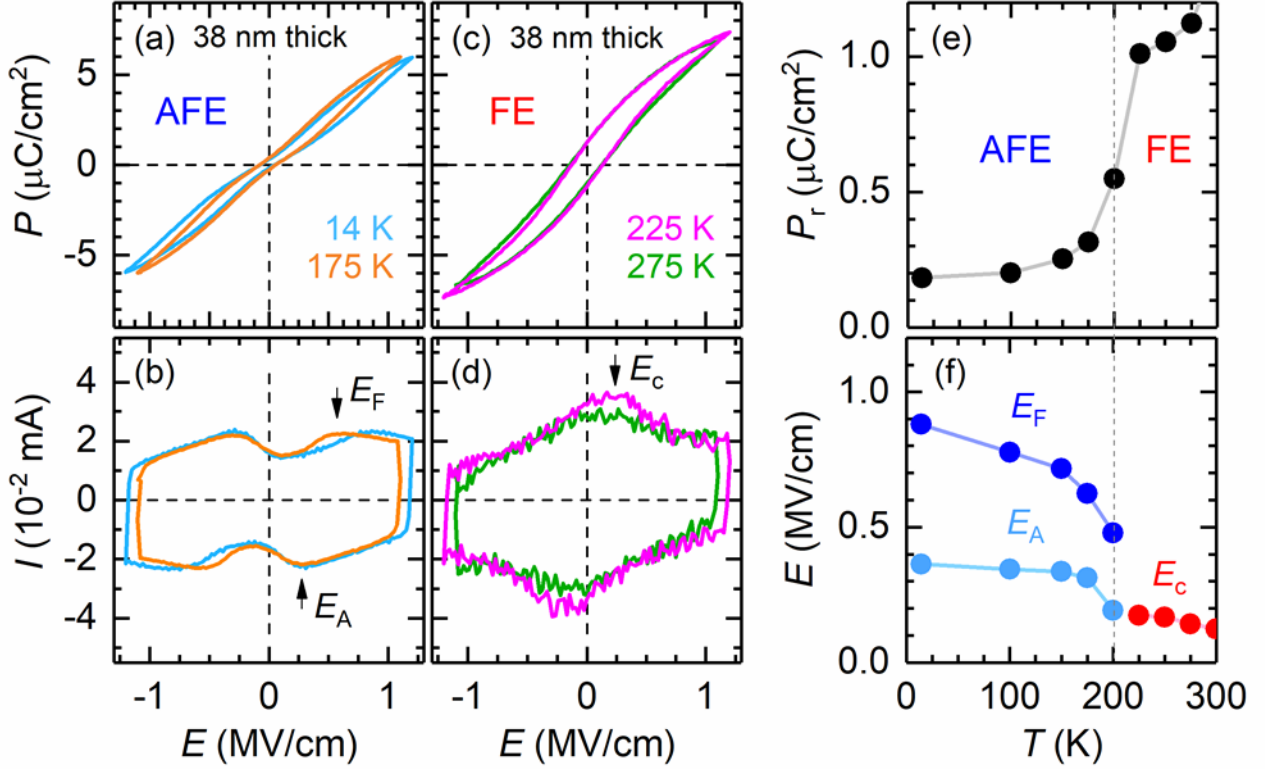
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2 **Figure 1.** (a) Out-of-plane XRD patterns, (b) lattice constants and (c) c/a of the h -DyFeO₃ films as a
 3 function of thickness.

4

5 Figure 2 shows the polarization and current versus electric field (P - E and I - E) curves for the
 6 38-nm-thick h -DyFeO₃ film. The measurements were conducted at 14–300 K at a frequency of 10 kHz.
 7 At $T \leq 175$ K, the P - E curves exhibited double-hysteresis loops (Fig. 2(a)). In addition, two positive
 8 and two negative peaks were observed in the I - E curve (Fig. 2(b)). These results indicated that the E -
 9 induced transition from nonpolar to polar states occurs at E_F and returns to a nonpolar state at E_A , i.e.,
 10 the film exhibits AFE behavior at $T \leq 175$ K. On the other hand, at $T \geq 225$ K, the P - E curves of the
 11 film show single-hysteresis loops (Fig. 2(c)) and the I - E curves have only one pair of peaks
 12 corresponding to coercive E (E_c) (Fig. 2(d)), indicating that the film showed FE behavior at $T \geq 225$
 13 K. Therefore, we can conclude that the film underwent a T -induced AFE–FE transition.

14

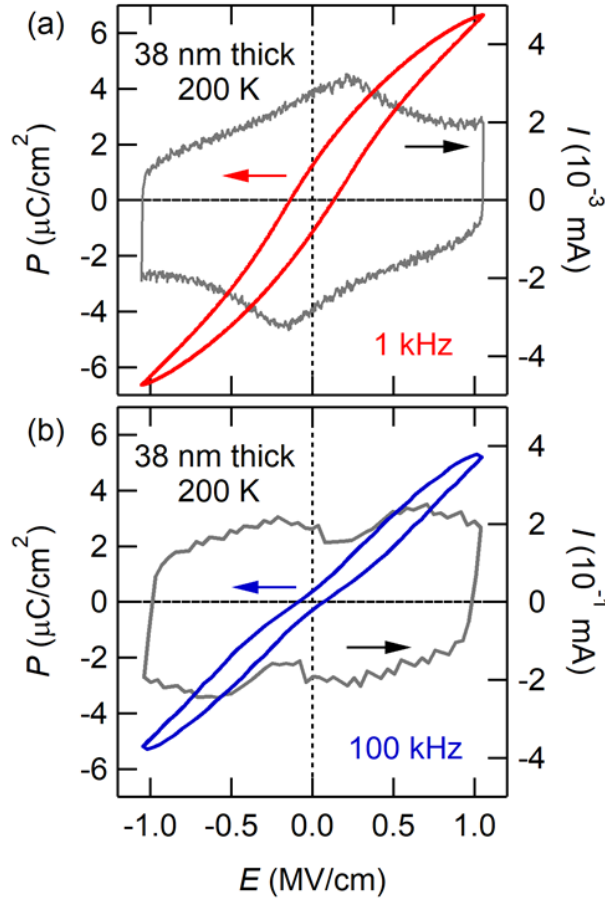


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2 **Figure 2.** P - E and I - E curves for the 38-nm-thick h -DyFeO₃ film at (a, b) 14, 175, (c, d) 225, and 275
3 K at 10 kHz. T dependence of (e) P_r and (f) E_F , E_A , and E_c for the film with maximum applied E of 1.1
4 MV/cm. The dashed line indicates the boundary between the AFE and FE phases.

5
6 Figure 2(e) shows the temperature (T) dependence of the remnant polarization (P_r) for the 38-
7 nm-thick film. The P_r value is 0.2–0.3 $\mu\text{C}/\text{cm}^2$ at $T \leq 175$ K, while it increases to >1 $\mu\text{C}/\text{cm}^2$ at $T \geq$
8 225 K associated with AFE–FE transition. Figure 2(f) shows the E_F , E_A , and E_c values for the film.
9 The E_A and E_F values decrease with increasing T and disappear at 225 K, while E_c appears at 225–300
10 K. From these results, we can conclude that the phase transition occurs at ~ 200 K.

11 Figure 3 shows frequency dependence of the P - E and I - E curves for the 38-nm-thick h -
12 DyFeO₃ film at the phase transition temperature of 200 K. When the frequency is 1 kHz, the film
13 shows a single-hysteresis loop in the P - E curve and a single pair of peaks in the I - E curve (Fig. 4(a)).
14 On the other hand, at 100 kHz, a double-hysteresis loop and two pairs of peaks appear in the P - E and
15 I - E curves, respectively. Thus, at the phase transition temperature, the h -DyFeO₃ film exhibited FE

1 and AFE behaviors at low and high frequencies, respectively.



2

3 **Figure 3.** P - E and I - E curves for the 38-nm-thick h -DyFeO₃ film at (a) 1 and (b) 100 kHz at 200 K.

4

5 We also performed ferroelectric measurements for the 26- and 58-nm-thick h -DyFeO₃ films.

6 The latter underwent a T -induced AFE-FE transition at 175 K (Fig. S7), The transition temperature is

7 lower than that for the 38-nm-thick film (200 K), presumably due to the larger c/a ratio of the 58-nm-

8 thick film (Fig. 1(c)). Figure 4 shows the P - E and I - E curves for the 26-nm-thick h -DyFeO₃ film as a

9 function of T . Below 100 K typical characteristics of AFE were detected: double-hysteresis loops in

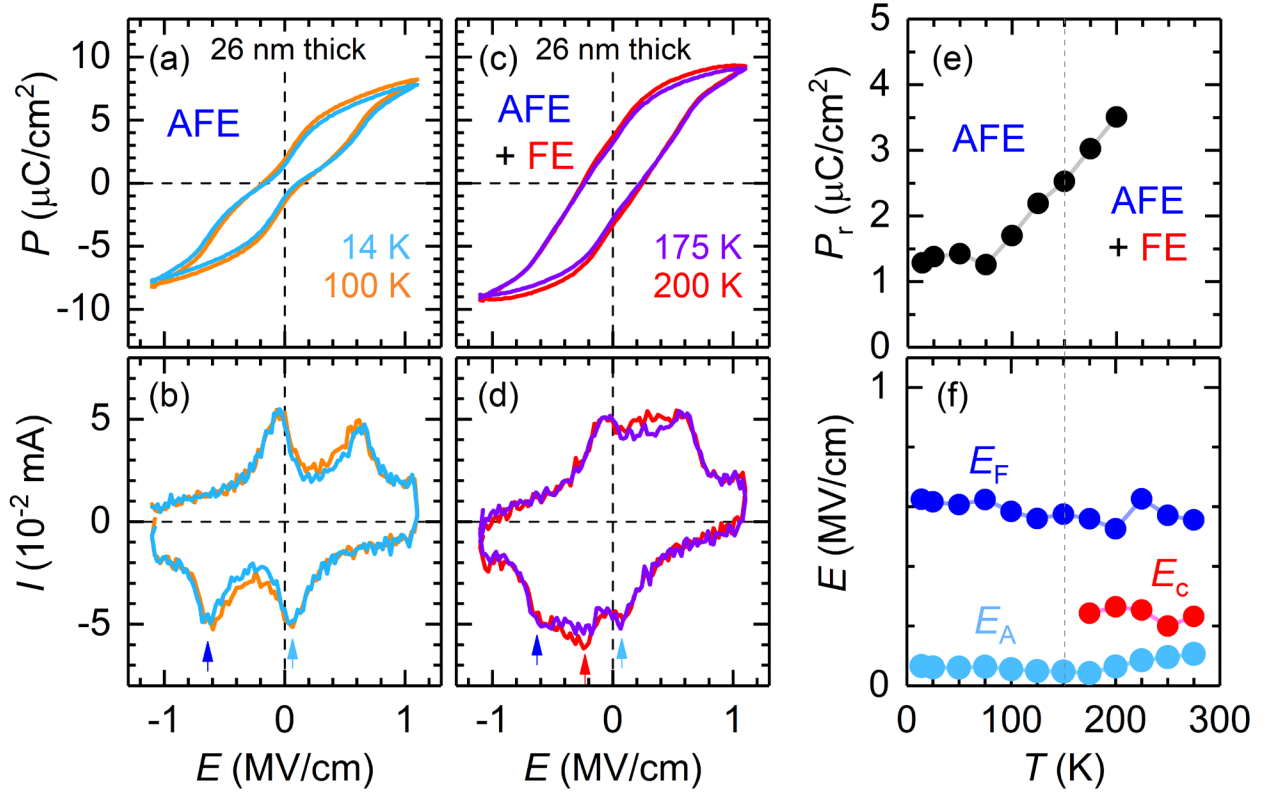
10 the P - E the curves (Fig. 4(a)) and two pairs of current peaks in the I - E curves (Fig. 4(b)). On the other

11 hand, at $T = 175$ -200 K, the double-hysteresis loops become insignificant in the P - E curves (Fig. 4(c)),

12 and new peaks corresponding to E_c appear between the E_A and E_F peaks in the I - E curves (Fig. 4(d)),

13 indicating the coexistence of AFE and FE phases at high T .

1



2

3 **Figure 4.** (a, b) P - E and (c, d) I - E curves for the 26-nm-thick h -DyFeO₃ film at (a, c) 14, 100, (b, d)
 4 175, and 200 K at 10 kHz. T dependence of (e) P_r and (f) E_F , E_A , and E_c for the film with maximum
 5 applied E of 1.1 MV/cm.

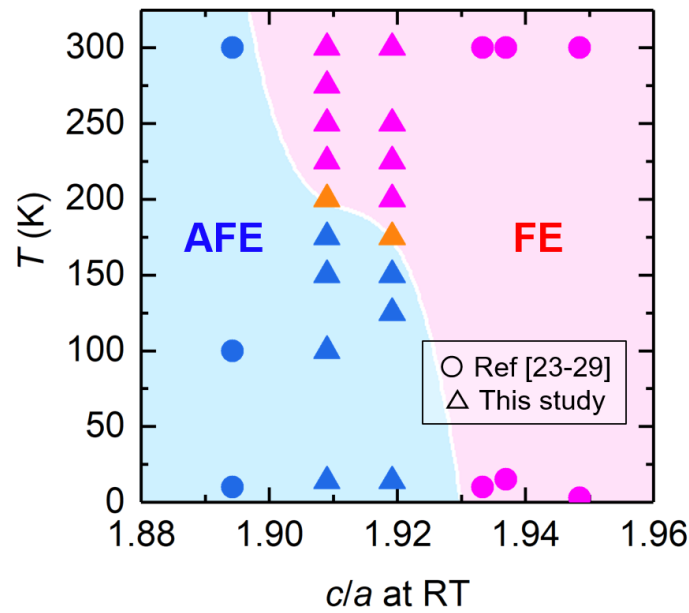
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7 Figure 4(e, f) shows the T dependence of P_r , E_A , E_F , and E_c for the 26-nm-thick h -DyFeO₃ film.
 8 With increasing T , the P_r values increased gradually from ~ 1.2 to $3.6 \mu\text{C}/\text{cm}^2$ without a significant
 9 jump, suggesting that the volume fraction of the FE phase in the film increased gradually. The E_A and
 10 E_F values were almost constant at ~ 0.2 and $0.6 \text{ MV}/\text{cm}$, respectively. At $T = 175$ – 300 K , the E_c peak
 11 emerges and coexists with the E_A and E_F peaks, showing that the film consists of both AFE and FE
 12 phases within a wide range of T (175 – 300 K). This behavior is different from those of the 38- and 58-
 13 nm-thick h -DyFeO₃ films (Figs. 2 and S7). It is speculated that the coexistence of AFE and FE phases
 14 in the 26-nm-thick film is derived, not necessarily from a change in the c/a ratio, but from a change in
 15 the thickness. For example, it is expected that the contribution of the interface effect to the ferroelectric

1 properties increases with decreasing thickness. Indeed, in h -YMnO₃, it was reported that mechanical
 2 clamping by the substrate affects the build-up of primary-order trimerization, leading to a strong
 3 thickness dependence of the polarization [36]. However, further investigation is needed to elucidate
 4 the origin of the coexistence of the AFE and FE phases.

5 Figure 5 shows the FE and AFE phase diagram of h -RFeO₃ in terms of c/a and T . The figure
 6 does not include the results for the 26-nm-thick h -DyFeO₃ film because its ferroelectric properties are
 7 strongly related to the thickness effect. As shown in the figure, FE and AFE phases are related to c/a
 8 and T ; increased c/a and T are conducive to triggering the FE phase. These results also suggest a
 9 possibility that the AFE–FE transition temperature could be adjusted to approximately room
 10 temperature via tuning the c/a ratio by changing the R ions and/or thickness.

11



12

13 **Figure 5.** Phase diagram of h -RFeO₃ as a function of c/a ratio and T .

14

15 Antiferroelectric behavior has also been observed in h -RMnO₃, which is isostructural with h -
 16 RFeO₃, by decreasing the c/a value [9 -11]. L. H. Yin *et al.* investigated the origin of the AFE behavior
 17 in h -RMnO₃ by preparing single crystals of FE h -YMnO₃ and AFE Cr-doped h -YMnO₃ (h -YMCO)

1 [37]. Unlike conventional AFE materials such as PbZrO_3 [38] and AgNbO_3 [39], AFE h -YMCO has
2 same crystal structure with FE h -YMnO₃. Thus, E -induced AFE–FE transition in h -YMCO is not
3 accompanied with a crystal structure transition. The important difference between h -YMnO₃ and h -
4 YMCO was observed in their unique topological domain structures. AFE h -YMCO has type-I domain
5 pattern, while FE h -YMnO₃ consists of type-II one. The type-I domain pattern contains roughly equal
6 fraction of upward and downward FE domains (P_{up} and P_{down}), resulting in zero net macroscopic P .
7 Thus, the AFE behavior in h -YMCO is strongly related to the domain wall (DW) motion. As one of
8 its unique features, it was reported that AFE behavior gradually disappears at low frequencies [37].
9 Such topological domain structures have been observed only in bulk single crystals [37, 40, 41]. **Indeed,**
10 **we could not observe such topological domain structures in the h -DyFeO₃ films using piezoresponse**
11 **force microscopy technique (Fig. S9). For the observation of domain structures of the film, preparation**
12 **of much thicker film may be needed.** However, considering that AFE h -DyFeO₃ has polar crystal
13 structure [24] and the AFE behavior gradually disappears at low frequency (Fig. 3), it is suggested that
14 AFE behavior of the h -DyFeO₃ film is also strongly related to the DW motion. Our experimental
15 results show that there are three factors that influence the AFE–FE transition of h -RFeO₃ films: c/a , T ,
16 and frequency, listed in the order of significance. T and frequency are related to migration length of
17 DW. Indeed, in FE h -ErMnO₃, an increase in P_r and a decrease in E_c were observed when T increased
18 or frequency decreased, due to an increase in migration length of DW [42]. On the other hand, when
19 c/a is small, the ferroelectric domain size decreased in the initial state as previously reported [24],
20 which probably results in an increase of the DW pinning centers and a resultant slow DW motion. It
21 is noted that small c/a , which is obtained when lattice constant parallel (perpendicular) to polarization
22 decreases (increases), tends to reduce the DW formation energy [43, 44].

23

24 **5. Conclusion**

25 In this study, we systematically investigated ferroelectric properties of the h -DyFeO₃ films by

1 controlling the c/a ratio in the range of 1.90–1.92, which is intermediate between those of previously
2 reported AFE and FE h - $R\text{FeO}_3$. As a result, we successfully observed T -induced AFE–FE phase
3 transition in the films. The AFE phase tends to stabilize at small c/a ratios and low temperatures.
4 Additionally, the coexistence of AFE and FE was observed in the thinner films at room temperature.
5
6

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12 a program of “Nanotechnology Platform” of the Ministry of Education, Culture, Sports, Science and
13 Technology (MEXT), Japan.
14

15 **Supporting information**

16 See supporting information for details of the crystal structures, chemical composition, and
17 ferroelectric properties of the films.
18

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